

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
)	
Seok-Woo LEE)	
)	
Application No.: Unassigned)	Group Art Unit: Unassigned
)	
Filed: October 30, 2003)	Examiner: Unassigned
)	
For: METHOD OF FORMING POLYSILICON THIN FILM TRANSISTOR		

Commissioner for Patents
MAIL STOP PATENT APPLICATION

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. § 1.97(b)

Pursuant to 37 C.F.R. §§ 1.56 and 1.97(b), Applicant brings to the attention of the Examiner the documents listed on the attached PTO-1449. This Information Disclosure Statement is being filed within three months of the filing date of the above-referenced application.

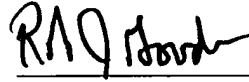
A copy of the listed document is attached.

This submission does not represent that a search has been made or that no better art exists and does not constitute an admission that the listed document is material or constitutes "prior art." If it should be determined that the listed document does not constitute "prior art" under United States law, Applicants reserve the right to present to the Office the relevant facts and law regarding the appropriate status of such document. Applicants further reserve the right to take appropriate action to establish the patentability of the disclosed invention over the listed document, should the document be applied against the claims of the present application.

If there is any fee due in connection with the filing of this Statement, please charge the fee to our Deposit Account No. 50-0310.

Respectfully submitted,

MORGAN, LEWIS & BOCKIUS LLP

A handwritten signature in black ink, appearing to read "RJ Goodell", is written over a horizontal line.

Robert J. Goodell, Reg. No. 41,040

Date: October 30, 2003

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INFORMATION DISCLOSURE CITATION (Use several sheets if necessary) PTO Form 1449	Attorney Docket No. 053785-5158	Serial No. Unassigned
	Applicants Seok-Woo LEE	
	Filing Date October 30, 2003	Group Unassigned

U.S. PATENT DOCUMENTS

*Examiner Initial	Document Number	Date	Name	Class	Sub Class	Filing Date

FOREIGN PATENT DOCUMENTS								
	Document Number	Date	Country	Class	Sub Class	Translation		
						YES	NO	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)		
		S. MATSUDA, et al. "Novel Corner Rounding Process For Shallow Trench Isolation Utilizing MSTs (Micro-Structure Transformation of Silicon)." IEDM Technical Digest. pp. 137-140, 1998.

Examiner	Date Considered
Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	